



IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Application Serial No. .... 10/678,513  
Filing Date ..... October 3, 2003  
Inventor ..... Werner Juengling  
Assignee ..... Micron Technology, Inc.  
Group Art Unit ..... 2812  
Examiner ..... Unknown  
Attorney's Docket No. .... MI22-2391  
Title: Semiconductor Processing Methods of Forming a Contact Opening to a  
Conductive Line and Methods of Forming Substrate Active Area  
Source/Drain Regions

**SUPPLEMENTAL INFORMATION DISCLOSURE STATEMENT**

References –See Attached Form PTO-1449


The Examiner's attention is directed to the references which are listed on the attached Form PTO-1449. No admission is made regarding whether all the submitted references are prior art.

Citation of the referenced art is respectfully requested.

This Supplemental Information Disclosure Statement is being filed before the mailing date of a first Office Action. Therefore, no fee is believed to be required. However, in the event that a fee is required for filing this Supplemental Information Disclosure Statement, please charge the fee specified under 37 C.F.R. § 1.17(p) to Deposit Account No. 23-0925.

Respectfully submitted,

Dated: S-11-04

By:   
D. Brent Kenady  
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